

INFORMATION DISCLOSURE STATEMENT

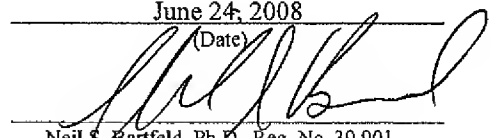
Applicant : Hirayama et al.
App. No : 10/590,046
Filed : June 15, 2007
For : BASE MATERIAL FOR PATTERN-
FORMING MATERIAL, POSITIVE
RESIST COMPOSITION AND
METHOD OF RESIST PATTERN
FORMATION
Examiner : Unassigned
Art Unit : 1795

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June 24, 2008

(Date)


Neil S. Bartfeld, Ph.D., Reg. No. 39,901

Mail Stop Amendment
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Dear Sir:

Enclosed for filing in the above-identified application is a PTO/SB/08 Equivalent listing 8 (eight) references to be considered by the Examiner. Also enclosed are 7 (seven) foreign patent references and/or non-patent literature as listed on the Information Disclosure Statement.

This Information Disclosure Statement is being filed before the receipt of a first Office Action on the merits, and presumably no fee is required. If a first Office Action on the merits was mailed before the mailing date of this Statement, the Commissioner is authorized to charge the fee set forth in 37 C.F.R. § 1.17(p) to Deposit Account No. 11-1410.

Respectfully submitted,

KNOBBE, MARTENS, OLSON & BEAR, LLP

Dated: 6/24/08

By: 

Neil S. Bartfeld, Ph.D.
Registration No. 39,901
Agent of Record
Customer No. 20,995
(619) 235-8550